

Fresnel-like formulas for the reflection and transmission of surface phonon-polaritons at a dielectric interface

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The reflection and transmission coefficients of a surface phonon-polariton propagating along the surface of a thin film of SiO₂ and crossing the interface of two dielectric media are analytically determined. Based on the expansion of the electrical and magnetic fields in terms of normal modes, explicit expressions for the reflectivity and transmissivity of the radiation fields generated at the dielectric interface are also obtained. Symmetrical and simple Fresnel-like formulas are derived for nanofilms. For the dielectric interfaces of air/BaF₂ and air/Al₂O₃, it is shown that: (i) The polariton reflectivity (transmissivity) decreases (increases) as the film thickness increases, while its radiation equivalent follows the opposite behavior. (ii) In the polariton and radiation fields, the transmissivity is significantly more sensitive than the reflectivity to the changes on the permittivity mismatch of the dielectric interface. For a 143-nm-thick film, the polariton transmissivity (reflectivity) changes 13.2% (1.9%), when this mismatch varies by 50%. (iii) The reflectivity and transmissivity of the radiation fields are smaller than their polariton counterparts, which together account for around 82% of the total energy. The proposed formalism accurately fulfills the principle of conservation of energy for describing the reflection and transmission of both the polariton and radiation fields generated at a dielectric interface.

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I. INTRODUCTION

Surface phonon-polaritons (SPPs) have been recently proposed [1–3] as potential energy carriers to enhance significantly the phonon heat transport in polar nanomaterials with low thermal conductivity, as is the case of the amorphous SiO₂ and crystalline SiC. Many theoretical [4–7] and experimental [8,9] studies have shown that the propagation length of SPPs traveling along the interface of nanofilms can be more than three orders of magnitude larger than the corresponding phonon mean free path, which yields in turn a SPP thermal conductivity comparable or higher than the phonon counterpart. We have also shown that the thermal conductance of polar nanowires due to SPPs is quantized and its value can be comparable to the one of phonons at room temperature [10]. Furthermore, various research groups have shown that the SPPs have promising applications on the thermal performance of nanoscale devices [4,8,11], radiative heat transfer [12–15], high-density infrared data storage [16], surface infrared absorption [17], coherent thermal emission [18], and photonics [19,20]. Given that SPPs are electromagnetic waves that propagate along the interface between polar and dielectric materials, their energy transport is expected to increase as the material size is scaled down to nanoscales, due to the predominance of the surface effects at these size scales [4,11].

SPP energy transport is determined by material permittivities and hence it can be modified by material discontinuities, which can be present in optical/electronic integrated circuits printed out on surfaces supporting the propagation of SPPs. The study of the reflection and transmission of SPPs at these discontinuities is thus of great practical interest and it has

attracted considerable experimental [21–23] and theoretical [24–26] interest in recent years. By using Fourier transform infrared spectroscopy, Chen *et al.* [21] measured the transmissivity through a 1- μ m-thick film of SiO₂ deposited over a substrate of a 500- μ m-thick silicon wafer and showed that the minima of the fraction of transmitted energy occur at the resonance wavelengths of absorption. For the major resonance peak, they found a fivefold increase in the transmission across a solid film through a perforated film with a periodic array of circular holes. These results are consistent with the numerical ones obtained by Catrysse and Fan [24] for the transmission through subwavelength hole arrays in a thin film of SiC, by means of a three-dimensional (3D) finite-difference time domain method. Similar experimental data were reported by Gall *et al.* [22] and Marquier *et al.* [23] for the reflectivity and transmissivity spectra in a SiC grating supporting the propagation of SPPs. Furthermore, by placing infinitely conducting metallic planes both above and below the propagation interface and making a waveguidelike structure, Stegeman *et al.* [25–27] numerically calculated the transmission and reflection coefficients for a surface plasmon-polariton crossing a plane boundary at normal incidence. They showed that these coefficients vary strongly with the ratio between the separation distance of the metallic planes and the polariton wavelength, such that the reflection (transmission) coefficient tends to zero (unity) as this ratio increases. Even though the formalism proposed by these latter authors is rigorous and could also be extended for SPPs, their numerical calculations are quite complicated and time consuming to implement, as was mentioned by the same authors [27].

In this paper, we analytically determine the reflection and transmission coefficients of a SPP propagating along the surface of a thin film of SiO₂ and crossing the interface of two dielectric media. Based on the expansion of the electrical and magnetic fields in terms of normal modes, explicit expressions

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for the reflection and transmission coefficients of the radiation fields generated at the dielectric interface are also derived. It is shown that these latter fields are indispensable for satisfying the boundary conditions and the principle of conservation of energy. Our results provide clear physical insights on how the SPP and radiation energy depends on the permittivity of the dielectric media as well as on the permittivity and thickness of the thin film.

II. FORMULATION OF THE PROBLEM AND NORMAL MODES

Let us consider a layered system supporting the propagation of a SPP, as shown in Fig. 1. The thin film of thickness d and permittivity $\varepsilon_1(\omega)$ is a polar material (as SiO₂ and SiC) deposited over a metallic substrate, which limits the generation of radiation modes at the vertical interface of the semi-infinite dielectric media of permittivities ε_2 and ε_3 [25]. When the incident SPP propagating along the interface 1–2 arrives to the vertical interface $z = 0$, it is partially reflected backward and transmitted to the interface 1–3. In general, the incident SPP can also be partially reflected and transmitted as electromagnetic radiation, which is predicted by the Maxwell equations and is required to satisfy the boundary conditions at $z = 0$, as shown below. The problem consists in finding the reflection and transmission coefficients of both the SPP and radiation electromagnetic fields, which will allow us to quantify the distribution of energy in the reflected and transmitted SPP, as well as in the radiation losses. By analogy with the problems involving waveguides, the electrical and magnetic fields for the SPP and radiation fields in each region of the system shown in Fig. 1 can be expressed in terms of the corresponding modes in absence of the discontinuity at $z = 0$ ($\varepsilon_2 = \varepsilon_3$). By solving the Maxwell equations under the transverse magnetic polarization, which is required for the existence of the incident SPP [4], it can be shown that the nonzero components of these fields are given by [28]

$$E_x^{(n)} = \frac{\beta}{\omega\varepsilon} H_y^{(n)}, \quad (1a)$$

$$E_z^{(n)} = \frac{1}{i\omega\varepsilon_n} \frac{\partial H_y^{(n)}}{\partial x}, \quad (1b)$$

$$\frac{\partial^2 H_y^{(n)}}{\partial x^2} - p_n^2 H_y^{(n)} = 0, \quad (1c)$$

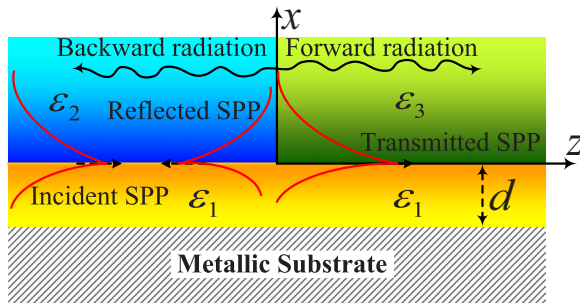


FIG. 1. (Color online) SPP and radiation modes generated by an incident SPP at a dielectric interface. The metallic substrate of the film of thickness d is used to diminish the radiation modes and enhance the SPP energy transport.

where β and p_n are the in-plane and transverse wave vectors, respectively, and they are related by $p_n^2 = \beta^2 - \varepsilon_n k_0^2$, $k_0 = \omega/c$, ω is the excitation frequency, c is the speed of light in vacuum, ε_n is the permittivity of the medium $n = 1, 2$, and $i = \sqrt{-1}$ is the imaginary unit. The electrical ($E_{x,z}^{(n)}$) and magnetic ($H_y^{(n)}$) components depend on the coordinate z and time t through their common factor $\exp[i(\omega t - \beta z)]$, which is omitted in Eqs. (1a)–(1c) and will be suppressed hereafter. For $\varepsilon_3 = \varepsilon_2$, Eq. (1c) establishes that the magnetic field inside the film ($H_y^{(1)}$) and the semi-infinite medium ($H_y^{(2)}$) are given by

$$H_y^{(1)} = A \cosh[p_1(x + d)], \quad (2a)$$

$$H_y^{(2)} = B e^{p_2 x} + C e^{-p_2 x}, \quad (2b)$$

where $H_y^{(1)}$ has been chosen in such a way that the associated electrical field $E_x^{(1)}$ satisfies the boundary condition $E_x^{(1)}(x = -d) = 0$, which is imposed by the metallic substrate [29]. The parameters A , B , and C are determined by the excitation source and the boundary conditions $H_y^{(1)} = H_y^{(2)}$ and $E_z^{(1)} = E_z^{(2)}$ at the interface $x = 0$. These latter relations yield

$$B + C = A \cosh(p_1 d), \quad (3a)$$

$$B - C = A \alpha_{21} \sinh(p_1 d), \quad (3b)$$

where $\alpha_{21} = \varepsilon_2 p_1 / \varepsilon_1 p_2$. Equations (1)–(3) are valid for both the SPP and radiation fields, which are going to be analyzed separately, as follows.

A. SPP modes

These modes are defined by the exponential decay [$\text{Re}(p_2) > 0$] of the fields as they travel away from the interface $x = 0$. This condition requires that $B = 0$, for which Eqs. (3a) and (3b) yield the following dispersion relation

$$\frac{p_2}{\varepsilon_2} + \frac{p_1}{\varepsilon_1} \tanh(p_1 d) = 0. \quad (4)$$

According to Eqs. (2) and (3a), the transverse magnetic field [$h(x) = H_y$] can be conveniently written as

$$h(x) = N_S \begin{cases} \cosh[p_1(x + d)], & -d < x < 0 \\ \cosh(p_1 d) e^{-p_2 x}, & x > 0 \end{cases}, \quad (5)$$

where $N_S = A$ for the SPP modes, and the transverse electrical field is given by $e(x) = (\beta/\omega\varepsilon)h(x)$ [see Eq. (1a)]. Equation (5) thus defines one SPP mode for each pair (p_1, p_2) of transverse wave vectors that satisfy the dispersion relation in Eq. (4). According to the Appendix A, these modes are orthogonal and they satisfy the normalization condition

$$\int_{-d}^{\infty} e(x) h^*(x) dx = 1, \quad (6a)$$

$$N_S^2 = \frac{2\omega\varepsilon_1}{\beta d \gamma}, \quad (6b)$$

$$\gamma = 1 + \frac{\sinh(2p_1 d)}{2p_1 d} + \frac{\varepsilon_1 \cosh^2(p_1 d)}{\varepsilon_2 p_2 d}, \quad (6c)$$

where the $*$ stands for the complex conjugate of $h(x)$.

B. Radiation modes

The electrical and magnetic fields of these modes are not spatially damped along the x direction and therefore they are defined by $\text{Re}(p_2) = 0$. In this case, the transverse wave vector

$$h(x, k) = N_R \begin{cases} \cosh[p_1(x + d)], & -d < x < 0 \\ \cosh(p_1 d) \cos(kx) + \xi \sinh(p_1 d) \sin(kx), & x > 0 \end{cases}, \quad (7)$$

where $N_R = A$ for the radiation modes, $\xi = \varepsilon_2 p_1 / \varepsilon_1 k$, and $\beta^2 = \varepsilon_2 k_0^2 - k^2 = p_1^2 + \varepsilon_1 k_0^2$. The corresponding electrical field is given by $e(x, k) = (\beta / \omega \varepsilon) h(x, k)$, as before. These radiation modes are also orthogonal and they are normalized by the following condition (Appendix A)

$$\int_{-d}^{\infty} e(x, k) h^*(x, k') dx = \delta(k - k'), \quad (8a)$$

$$N_R^2 = \frac{2\omega \varepsilon_2}{\pi \beta(k) \gamma_R}, \quad (8b)$$

$$\gamma_R = |\cosh[p_1(k)d]|^2 + |\xi \sinh[p_1(k)d]|^2. \quad (8c)$$

We can now use the previous SPP and radiation modes to express the electrical and magnetic fields involved in the system shown in Fig. 1. Let $e_0^<(x)$ and $h_0^<(x)$ [$e_0^>(x)$ and $h_0^>(x)$] be the transverse components of the electrical and magnetic fields of the incident (transmitted) SPP, respectively and $e^<(x, k)$ and $h^<(x, k)$ [$e^>(x, k)$ and $h^>(x, k)$] be the corresponding electromagnetic fields of the backward (forward) radiation modes. The transverse components of the total electromagnetic fields in the regions $z < 0$ ($E_x^<, H_y^<$) and $z > 0$ ($E_x^>, H_y^>$) can then be expressed as follows [30]:

$$E_x^<(x, z) = e_0^<(x) (e^{-iz\beta^<} - r e^{iz\beta^<}) - \int_0^{\infty} r_R(k) e^<(x, k) e^{iz\beta_R^<} dk, \quad (9a)$$

$$H_y^<(x, z) = h_0^<(x) (e^{-iz\beta^<} + r e^{iz\beta^<}) + \int_0^{\infty} r_R(k) h^<(x, k) e^{iz\beta_R^<} dk, \quad (9b)$$

$$E_x^>(x, z) = \tau e_0^>(x) e^{-iz\beta^>} + \int_0^{\infty} \tau_R(k) e^>(x, k) e^{-iz\beta_R^>} dk, \quad (9c)$$

$$H_y^>(x, z) = \tau h_0^>(x) e^{-iz\beta^>} + \int_0^{\infty} \tau_R(k) h^>(x, k) e^{-iz\beta_R^>} dk, \quad (9d)$$

where r and τ (r_R and τ_R) are the reflection and transmission coefficients of the SPP (radiation) fields, respectively, and $\beta^<$ and $\beta^>$ ($\beta_R^<$ and $\beta_R^>$) are the SPP (radiation) wave vectors along the propagation direction, for $z < 0$ and $z > 0$, respectively. The continuity of the tangential electrical [$E_x^<(x, 0) = E_x^>(x, 0)$] and magnetic [$H_y^<(x, 0) = H_y^>(x, 0)$]

p_2 can be defined as $p_2 = -ik$, where $k > 0$ is the radiation wave vector along the transverse x direction. Based on Eqs. (2) and (3) and by analogy with the SPP modes, the radiation modes can be defined as follows

fields at the dielectric interface $z = 0$ yields

$$(1 - r) e_0^<(x) - \int_0^{\infty} r_R(k) e^<(x, k) dk = \tau e_0^>(x) + \int_0^{\infty} \tau_R(k) e^>(x, k) dk, \quad (10a)$$

$$(1 + r) h_0^<(x) + \int_0^{\infty} r_R(k) h^<(x, k) dk = \tau h_0^>(x) + \int_0^{\infty} \tau_R(k) h^>(x, k) dk. \quad (10b)$$

Note that in absence of the radiation terms, Eqs. (10a) and (10b) cannot be satisfied because of the transverse wave vectors in the region $z < 0$ are different than the corresponding ones in $z > 0$. It is therefore clear that the presence of the radiation modes are indispensable to satisfy these boundary conditions. This mode matching approach was previously applied to numerically determine the reflection and transmission coefficients of surface plasmon-polaritons at dielectric interfaces [31,32]. To eliminate the dependence on the variable x and to solve Eqs. (10a) and (10b) for the coefficients r , τ , r_R , and τ_R , it is convenient to define the following inner product

$$(f, g) = \int_{-d}^{\infty} f(x) g^*(x) dx, \quad (11)$$

where f and g are functions of x over the interval of integration. Multiplying Eq. (10a) by $(h_0^<)^*$ and Eq. (10b) by $(e_0^>)^*$ and integrating both sides over the interval $-d < x < \infty$, the following expressions are found for τ

$$\tau = (1 - r) (e_0^<, h_0^>) - \int_0^{\infty} r_R(k) [e^<(k), h_0^>] dk, \quad (12a)$$

$$\tau = (1 + r) (h_0^<, e_0^>) + \int_0^{\infty} r_R(k) [h^<(k), e_0^>] dk, \quad (12b)$$

where we have used the normalization condition in Eq. (6a) for the SPP modes and the orthogonality of the SPP and radiation modes, which is discussed in Appendix A. By following a similar procedure, it is easy to show that τ_R is determined by

$$\tau_R(k) = (1 - r) [e_0^<, h^>(k)] - \int_0^{\infty} r_R(k') [e^<(k'), h^>(k)] dk', \quad (13a)$$

$$\tau_R(k) = (1 + r) [h_0^<, e^>(k)] + \int_0^{\infty} r_R(k') [h^<(k'), e^>(k)] dk'. \quad (13b)$$

Equations (12) and (13) show that the exact determination of the reflection and transmission coefficients is quite complicated due to the presence of the integral terms. However, for dielectric media with permittivities ε_2 and ε_3 of the same order of magnitude, both reflection coefficients are expected to be close to zero ($r, r_R \rightarrow 0$), and the electromagnetic modes in the regions $z < 0$ and $z > 0$ are approximately orthogonal $\{(e^<(k), h_0^>), [h^<(k), e_0^>], (e_0^<, h^>(k)), [h_0^<, e^>(k)]\} \rightarrow 0$ and $[e^<(k'), h^>(k)] \approx \delta(k - k')$. Under these conditions and a first-order approximation of Eqs. (12) and (13), it is found that the reflection and transmission coefficients of the SPP and radiation modes are analytically given by

$$r = \frac{(e_0^<, h_0^>) - (h_0^<, e_0^>)}{(e_0^<, h_0^>) + (h_0^<, e_0^>)}, \quad (14a)$$

$$\tau = \frac{2(e_0^<, h_0^>)(h_0^<, e_0^>)}{(e_0^<, h_0^>) + (h_0^<, e_0^>)}, \quad (14b)$$

$$2r_R(k) = [e_0^<, h^>(k)] - [h_0^<, e^>(k)], \quad (14c)$$

$$2\tau_R(k) = [e_0^<, h^>(k)] + [h_0^<, e^>(k)]. \quad (14d)$$

Note that while the SPP reflection and transmission coefficients depend only on inner products of SPP modes, their radiation counterparts are determined by inner products between the SPP modes in $z < 0$ with radiation modes in $z > 0$. This means that the origin of the radiation fields is the incident SPP field, as expected. After evaluating the inner products in Eqs. (14a)–(14d) with the help of Eqs. (5)–(8) and (11), the reflection and transmission coefficients can be written explicitly as follows

$$r = \frac{\varepsilon_2 \varepsilon_3 (\beta^< - \beta^>) I_1 + \varepsilon_1 (\varepsilon_3 \beta^< - \varepsilon_2 \beta^>) I_2}{\varepsilon_2 \varepsilon_3 (\beta^< + \beta^>) I_1 + \varepsilon_1 (\varepsilon_3 \beta^< + \varepsilon_2 \beta^>) I_2}, \quad (15a)$$

$$\tau = \sigma \frac{(\varepsilon_2 I_1 + \varepsilon_1 I_2)(\varepsilon_3 I_1 + \varepsilon_1 I_2)}{\varepsilon_2 \varepsilon_3 (\beta^< + \beta^>) I_1 + \varepsilon_1 (\varepsilon_3 \beta^< + \varepsilon_2 \beta^>) I_2}, \quad (15b)$$

$$r_R = \sigma \left[(\beta^< - (\beta_R^>)^*) \frac{J_1}{\varepsilon_1} + \left(\frac{\beta^<}{\varepsilon_2} - \frac{(\beta_R^>)^*}{\varepsilon_3} \right) J_2 \right], \quad (15c)$$

$$\tau_R = \sigma \left[(\beta^< + (\beta_R^>)^*) \frac{J_1}{\varepsilon_1} + \left(\frac{\beta^<}{\varepsilon_2} + \frac{(\beta_R^>)^*}{\varepsilon_3} \right) J_2 \right], \quad (15d)$$

where the parameters $\sigma = 4\sqrt{\beta^<\beta^>}/\delta^<\delta^>$, $\sigma_R = \sqrt{\varepsilon_1 \varepsilon_3 d / (\beta^< (\beta_R^>)^* \delta^<\eta^>)}$, and the dimensionless integrals

$$I_1 = \frac{1}{2} \left[\frac{\sinh[(p_1^< + p_1^>)d]}{(p_1^< + p_1^>)d} + \frac{\sinh[(p_1^< - p_1^>)d]}{(p_1^< - p_1^>)d} \right], \quad (16a)$$

$$I_2 = \frac{\cosh(p_1^<d) \cosh(p_1^>d)}{(p_2 + p_3)d}, \quad (16b)$$

$$J_1 = \frac{1}{2} \left[\frac{\sinh\{[p_1^< + (p_{1R}^>)^*]d\}}{[p_1^< + (p_{1R}^>)^*]d} + \frac{\sinh\{[p_1^< - (p_{1R}^>)^*]d\}}{[p_1^< - (p_{1R}^>)^*]d} \right], \quad (16c)$$

$$J_2 = \frac{\cosh(p_1^<d)}{(p_2^2 + k^2)d} \left[p_2 \cosh[(p_{1R}^>)^*d] + \frac{\varepsilon_3}{\varepsilon_1} (p_{1R}^>)^* \sinh[(p_{1R}^>)^*d] \right]. \quad (16d)$$

Equations (15a)–(15d) clearly show that the reflection and transmission coefficients for the SPP and radiation fields

depend strongly on the permittivity mismatch of the semi-infinite media, as well as on the permittivity and thickness of the thin film. In absence of the dielectric interface ($\varepsilon_3 = \varepsilon_2$), the in-plane wave vectors $\beta^< = \beta^>$ and therefore $r = 0$, $\tau = 1$, and $r_R = \tau_R = 0$, as expected. For very thin ($k_0 d \ll 1$) and very thick ($k_0 d \gg 1$) films, Eqs. (15a) and (15b) becomes independent of the film thickness d and they can be significantly simplified. In the first limiting case, Eqs. (15a) and (15b) reduce to

$$r_0 = \frac{\sqrt{\varepsilon_3} - \sqrt{\varepsilon_2}}{\sqrt{\varepsilon_3} + \sqrt{\varepsilon_2}}, \quad (17a)$$

$$\tau_0 = 4 \frac{\sqrt{\varepsilon_2 \varepsilon_3} \sqrt{\varepsilon_2 \varepsilon_3 (\varepsilon_2 - \varepsilon_1) (\varepsilon_3 - \varepsilon_1)}}{\sqrt{\varepsilon_2} + \sqrt{\varepsilon_3} \varepsilon_2 (\varepsilon_2 - \varepsilon_1) + \varepsilon_3 (\varepsilon_3 - \varepsilon_1)}, \quad (17b)$$

where the subscript 0 indicates that the formulas are valid for ($k_0 d \ll 1$). For thick films, on the other hand, Eqs. (15a) and (15b) take the form

$$r_\infty = \frac{\varepsilon_2 \varepsilon_3 (\beta^< - \beta^>) + \varepsilon_1 (\varepsilon_3 \beta^< - \varepsilon_2 \beta^>) \chi}{\varepsilon_2 \varepsilon_3 (\beta^< + \beta^>) + \varepsilon_1 (\varepsilon_3 \beta^< + \varepsilon_2 \beta^>) \chi}, \quad (18a)$$

$$\tau_\infty = \psi \frac{(\varepsilon_2 + \varepsilon_1 \chi)(\varepsilon_3 + \varepsilon_1 \chi)}{\varepsilon_2 \varepsilon_3 (\beta^< + \beta^>) + \varepsilon_1 (\varepsilon_3 \beta^< + \varepsilon_2 \beta^>) \chi}, \quad (18b)$$

$$\chi = -\frac{\varepsilon_1 (p_1^< + p_1^>)}{\varepsilon_2 p_1^< + \varepsilon_3 p_1^>}, \quad (18c)$$

$$\psi = -\frac{4\varepsilon_2 \varepsilon_3 \sqrt{\beta^<\beta^> p_1^< p_1^>}}{(p_1^< + p_1^>) \sqrt{(\varepsilon_1^2 - \varepsilon_2^2)(\varepsilon_1^2 - \varepsilon_3^2)}}, \quad (18d)$$

where $\beta^< = k_0 \sqrt{\varepsilon_1 \varepsilon_2 / (\varepsilon_1 + \varepsilon_2)}$, $\beta^> = k_0 \sqrt{\varepsilon_1 \varepsilon_3 / (\varepsilon_1 + \varepsilon_3)}$, $p_1^< = \sqrt{-\varepsilon_1 / \varepsilon_2 \beta^<}$, $p_1^> = \sqrt{-\varepsilon_1 / \varepsilon_3 \beta^>}$, and the subscript ∞ stands for $k_0 d \gg 1$. Note that both $r_0(\varepsilon_2, \varepsilon_3) = -r_0(\varepsilon_3, \varepsilon_2)$ and $r_\infty(\varepsilon_2, \varepsilon_3) = -r_\infty(\varepsilon_3, \varepsilon_2)$, which means that when the semi-infinite media are interchanged, the reflection coefficient of the reflected SPP changes by a phase reversal only. This behavior coincides with the one exhibited by the corresponding Fresnel equation for normal incidence of plane waves [29]. By contrast, this phase reversal is not present in the transmission coefficient, which is invariant under the interchange of the semi-infinite media [$\tau_0(\varepsilon_2, \varepsilon_3) = \tau_0(\varepsilon_3, \varepsilon_2)$ and $\tau_\infty(\varepsilon_2, \varepsilon_3) = \tau_\infty(\varepsilon_3, \varepsilon_2)$]. Given that the energy fractions of the reflected and transmitted SPP are given by the square of the magnitude of r and τ , respectively, as shown below, the aforementioned features of the SPP reflection and transmission coefficients establish that the energy of the reflected and transmitted SPP keeps invariant under the interchange of the dielectric media. This feature is exclusive of SPPs and is not present in the radiation fields, as indicated by Eqs. (15c) and (15d).

The accuracy of the simple and approximate expressions for the reflection and transmission coefficients in Eqs. (14a)–(14d) can be evaluated by calculating the integrals in Eqs. (12) and (13) with the estimated value of the reflection coefficient of the radiation modes in Eq. (14c). In doing this, the following expressions for the differences Δr , $\Delta \tau$, and $\Delta \tau_R(k)$ between the exact expressions of the reflection and transmission coefficients [Eqs. (12) and (13)], and their corresponding approximate results [Eqs. (14a), (14b), and

(14d)] are obtained

$$\Delta r = -\frac{\int_0^\infty r_R(k)\{[e^<(k), h_0^>] + [h^<(k), e_0^>]\}dk}{(e_0^<, h_0^>) + (h_0^<, e_0^>)}, \quad (19a)$$

$$\Delta \tau = \frac{\int_0^\infty r_R(k)\{(e_0^<, h_0^>)[h^<(k), e_0^>] - (h_0^<, e_0^>)[e^<(k), h_0^>]\}dk}{(e_0^<, h_0^>) + (h_0^<, e_0^>)}, \quad (19b)$$

$$\Delta \tau_R(k) = \frac{1}{2} \int_0^\infty r_R(k')\{[h^<(k'), e^>(k)] - [e^<(k'), h^>(k)]\}dk'. \quad (19c)$$

Given the complicate dependence of $r_R(k)$ on the wave vector k [Eq. (15c)], the integrals in Eqs. (19a)–(19c) cannot be evaluated analytically. For very thin film ($k_0d \ll 1$), which is the case of major interest to enhance the propagation of SPPs [4,11], these integrals simplify significantly and the deviations exhibit the following behavior

$$\Delta r \text{ and } \Delta \tau \propto \sqrt{(\varepsilon_2 - \varepsilon_1)(\varepsilon_3 - \varepsilon_1)}(k_0d)^3 \quad (20a)$$

$$\Delta \tau_R(k) \propto \sqrt{(\varepsilon_2 - \varepsilon_1)}(k_0d)^2, \quad (20b)$$

which explicitly indicate that for $k_0d \ll 1$, our approximate results in Eqs. (14a)–(14d) are accurate and their accuracy is expected to increase as the film thickness decreases. The fact that the SPP coefficients are proportional to the third power of the film thickness, while radiation one is proportional to the second power of this thickness shows that the approximate expression of the reflection and transmission coefficients of the SPP modes become more accurate than the transmission coefficient of the radiation modes as the film thickness is scaled down.

The power flow per unit film width of the reflected and transmitted SPP and radiation fields can now be calculated through the Poynting vector S along the propagation direction (z axis), which is defined by

$$S = \frac{1}{2} \text{Re} \left(\int_{-d}^\infty E_x(x,0) H_y^*(x,0) dx \right). \quad (21)$$

Based on Eqs. (9) and (21), we can determine the power of the incident (S^{inc}), reflected (S^{ref}), and transmitted (S^{tran}) SPP as well as the power of the reflected (S_R^{ref}) and transmitted (S_R^{tran}) radiation fields. The reflectivity and transmissivity of the SPP and radiation fields are therefore defined as $R = -S^{\text{ref}}/S^{\text{inc}}$, $T = S^{\text{tran}}/S^{\text{inc}}$, $R_R = -S_R^{\text{ref}}/S^{\text{inc}}$, and $T_R = S_R^{\text{tran}}/S^{\text{inc}}$. In terms of the reflection and transmission coefficients, these relations yield

$$R = |r|^2, \quad (22a)$$

$$T = |\tau|^2, \quad (22b)$$

$$R_R = \int_0^\infty |r_R(k)|^2 dk, \quad (22c)$$

$$T_R = \int_0^\infty |\tau_R(k)|^2 dk. \quad (22d)$$

Given that all the energy of the incident SPP is transferred to the reflected and transmitted SPP and radiation fields, the principle of conservation of energy establishes that

$$R + T + R_R + T_R = 1. \quad (23)$$

We will show below that the approximate, simple, and analytical results for the reflection and transmission coefficients involved in Eqs. (22a)–(22d) are able to satisfy Eq. (23) with an error less than 2%.

III. RESULTS AND DISCUSSIONS

The reflectivity and transmissivity of the SPP and radiation fields generated by an incident SPP crossing the dielectric interface shown in Fig. 1 are quantified and analyzed in this section. Special emphasis is put on the effects of the film thickness and permittivities of the dielectric media. We consider a film of amorphous SiO₂ (silica), which is an abundant polar material in nature and widely used in electronic applications [1,4]. Furthermore, SiO₂ is commonly employed in the manufacturing of electrical circuits, in which thermal sources generated by Joule effect might be cooled via SPPs. For the dielectric media, we are going to use air, as a natural surrounding medium, in contact with BaF₂ or Al₂O₃ (alumina), which are transparent crystals in a wide range of frequencies [33] and are used in many applications related to optics, infrared spectroscopy, and electronics. All of these materials behave as lossless materials (with real permittivities) at the frequency $\omega = 210 \times 10^{12}$ rad/s ($k_0 = 0.7 \mu\text{m}^{-1}$), which is going to be used in this work, to guaranty the orthogonality of the SPP and radiation modes and to simplify the energy distribution analysis based on the Poynting vector, as discussed in Appendix A.

Figure 2 shows the film-thickness dependence of the wave vector β along the propagation direction of a SPP traveling via the interface of a film of SiO₂ and a dielectric medium, as shown in Fig. 1. Calculations were done using the dispersion relation in Eq. (4) and its analysis in Appendix B. It is seen that β increases with the film thickness, such that it reaches asymptotic values for very thin ($k_0d \ll 1$) and very thick ($k_0d \gg 1$) films. The thick-film limit is given by the well known dispersion relation $\beta = \sqrt{\varepsilon_1 \varepsilon_2 / (\varepsilon_1 + \varepsilon_2)} k_0$, and the thin-film one is described by the simple solution of the dispersion relation in Eq. (29). Given that $k_0 = 0.7 \mu\text{m}^{-1}$, this latter limit holds for films with thicknesses ($d \ll 1.4 \mu\text{m}$) from hundreds of nanometers downwards, which represent the regime of major energy transport by SPPs [6,7,11]. Note that irrespective of the the film thickness, the in-plane wave vector increases with the permittivity of the dielectric media and it is greater than the one in vacuum ($\beta > k_0$), which indicates that the SPP is propagating with a wave vector to the right of the light line [11]. Furthermore, it is clear that $\beta \rightarrow k_0$, when the thickness and/or the dielectric permittivity

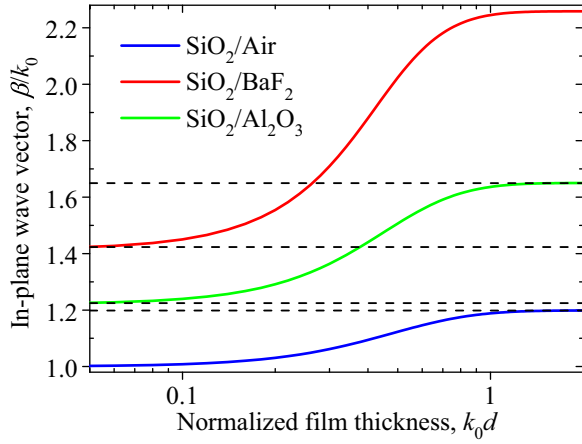


FIG. 2. (Color online) Normalized in-plane wave vector of a SPP propagating along the interface of a thin film of SiO₂ and a dielectric medium, as a function of the normalized film thickness. Calculations were performed for $\epsilon(\text{Air}) = 1$, $\epsilon(\text{BaF}_2) = 2$, $\epsilon(\text{Al}_2\text{O}_3) = 1.5$, and $\epsilon(\text{SiO}_2) = -3.3$; which occur at $k_0 = 0.7 \mu\text{m}^{-1}$ [11,33].

reduces, which implies a photonlike nature of the SPP. As these parameters increase, β/k_0 separates from the unity and tends to a phononlike behavior.

The film-thickness dependence of the normalized transverse wave vectors in the regions $z < 0$ ($p_1^<$, p_2) and $z > 0$ ($p_1^>$, p_3) are shown in Fig. 3, for the air/BaF₂ dielectric interface. As in the case of the in-plane wave vector β , the transverse wave vectors increase with the film thickness and they become independent of this thickness for very thin ($k_0d \ll 1$) and very thick ($k_0d \gg 1$) films. For a given film thickness, these wave vectors are larger in the medium with higher absolute value of permittivity, as established by the dispersion relation in Eq. (4) and its analytical solution in Eq. (29). The fact that all transverse wave vectors are positive indicates that the electrical and magnetic fields of the SPPs decay spatially as they travel away from the propagation

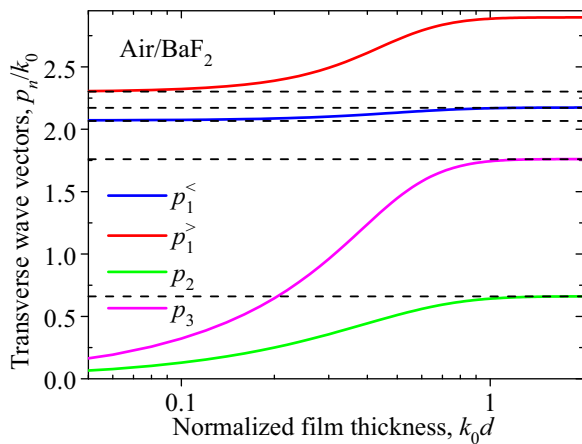


FIG. 3. (Color online) Normalized transverse wave vector of a SPP propagating along the surface of a SiO₂ film and crossing a dielectric interface of air/BaF₂ (see Fig. 1), as a function of the normalized film thickness. Calculations were performed with the data used in Fig. 2.

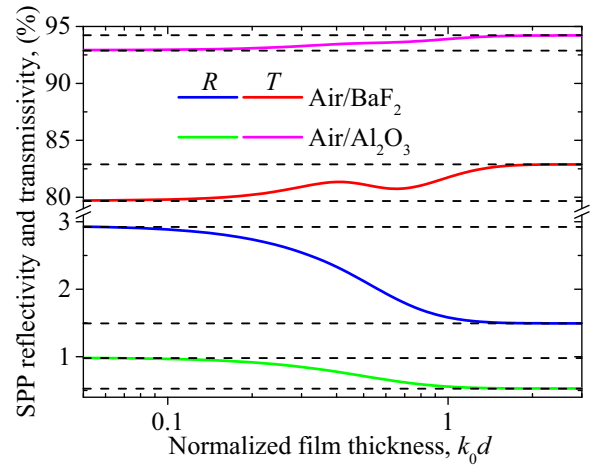


FIG. 4. (Color online) Reflectivity and transmissivity of a SPP propagating along the surface of a SiO₂ film and crossing a dielectric interface, as a function of the normalized film thickness. Calculations were done for two dielectric interfaces of Air/BaF₂ and Air/Al₂O₃, and with the data used in Fig. 2.

interface $x = 0$, which guaranties the existence of SPPs [4,11]. Given that $|\epsilon(\text{SiO}_2)| > \epsilon(\text{BaF}_2) > \epsilon(\text{air})$, the transverse spatial attenuation inside the thin film is stronger than the one in BaF₂, which in turn is more intense than the one within air. It is therefore clear that the SPP fields within the SiO₂ film are more confined to the propagation interface than those in the dielectric media.

Figure 4 shows that reflectivity R and transmissivity T of the SPP fields as a function of the normalized film thickness and for two dielectric interfaces. For both cases, R decreases as the film thickness increases, while T exhibits the opposite trend; and they tend to thickness-independent values for very thin ($k_0d \ll 1$) and very thick ($k_0d \gg 1$) films, which is consistent with the behavior of the SPP wave vectors shown in Figs. 2 and 3. For nanofilms, R and T are described by the simple and symmetrical formulas in Eqs. (17) and (20), while for microfilms, they are determined by a little more complicated but still analytical formulas in Eqs. (18) and (20). Equations (17) and (18) can thus be considered as the Fresnel-like equations for the reflection and transmission of SPPs across the dielectric interface shown in Fig. 1. Note that the reflectivity (transmissivity) for the dielectric interface of Air/BaF₂ is higher (lower) than the corresponding one of the interface Air/Al₂O₃. This is quite reasonable due to the fact that the permittivity mismatch between the dielectric media in the Air/BaF₂ interface ($\epsilon_3 - \epsilon_2 = 1$) is higher than that for the another interface ($\epsilon_3 - \epsilon_2 = 0.5$). For this modification on the dielectric interface ($\Delta\epsilon_3 = 0.5$) and $k_0d = 0.1$ ($d = 143 \text{ nm}$), the change on the reflectivity is $\Delta R = 1.9\%$, which rises to $\Delta T = 13.2\%$ for the transmissivity. The SPP transmissivity is therefore more sensitive than the SPP reflectivity to the changes on the permittivity mismatch of the dielectric interface.

The magnitudes $|\Delta r|$ and $|\Delta \tau|$ of the deviations defined in Eqs. (19a) and (19b) for the reflection and transmission coefficients of the SPP modes are shown in Fig. 5, as a function of the normalized film thickness. For thin ($k_0d \ll 1$) and thick

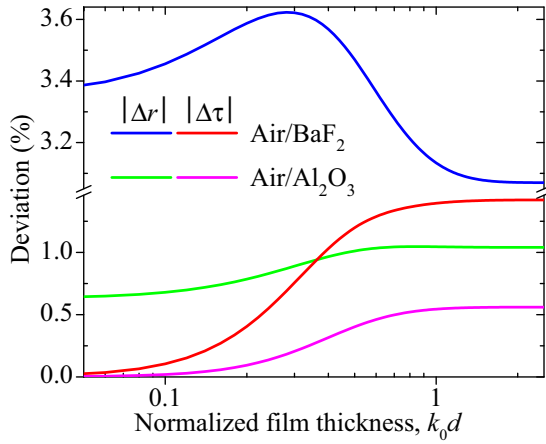


FIG. 5. (Color online) Deviations of the reflection and transmission coefficients of the SPP modes propagating along the surface of a SiO₂ film and crossing a dielectric interface, as a function of the normalized film thickness. Calculations were done for two dielectric interfaces of Air/BaF₂ and Air/Al₂O₃, and with the data used in Fig. 2.

($k_0d \gg 1$) films, both $|\Delta r|$ and $|\Delta \tau|$ becomes independent of the film thickness and they take smaller values for thinner films. This is consistent with Eq. (20a) and the predictions of the principle of conservation of energy shown below in Fig. 8. The deviations of the reflection and transmission coefficients for the Air/BaF₂ interface are greater than their corresponding ones for the Air/Al₂O₃ interface, due to the fact that the permittivity mismatch of the first interface ($\epsilon_3 - \epsilon_2 = 1$) is greater than that of the latter one ($\epsilon_3 - \epsilon_2 = 0.5$). This confirms that Eqs. (14a) and (14b) become more accurate as the difference of permittivities of the dielectric media reduces. Furthermore, the fact that $|\Delta \tau| < |\Delta r| < 3.6\%$ for both dielectric interfaces, indicates that the reflectivity and transmissivity shown in Fig. 4 have high accuracy, with a slight deviation from their corresponding exact values comparable or smaller than 3.6%, as established by Eqs. (22a) and (22b).

The spectra of the reflectivity and transmissivity of the radiation fields generated by the incident SPP at the dielectric interface Air/BaF₂ are shown in Figs. 6(a) and 6(b), respectively, as a function of the normalized radiation wave

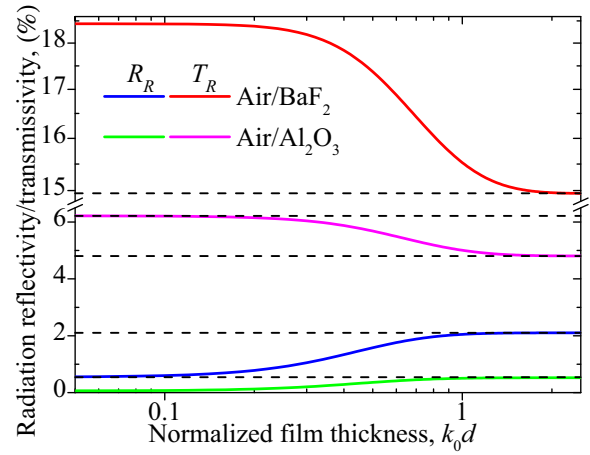


FIG. 7. (Color online) Reflectivity and transmissivity of the radiation fields generated by a SPP propagating along the surface of a SiO₂ film and crossing a dielectric interface, as a function of the normalized film thickness. Calculations were done for two dielectric interfaces of Air/BaF₂ and Air/Al₂O₃, and with the data used in Fig. 2.

vector k/k_0 . Both spectra follow a similar behavior, which does not vary significantly for film thicknesses $k_0d > 1$ and $k/k_0 < \sqrt{\epsilon_3}$. Within this range of the radiation wave vector, the wave vector $\beta_R^>$ is real, as established just below Eq. (7) while for $k/k_0 > \sqrt{\epsilon_3}$, $\beta_R^>$ becomes an imaginary number, which leads to the oscillations of the spectra. In this latter interval of the radiation wave vector both spectra decay fast to zero as k/k_0 increases, which indicates that the major contributions to R_R and T_R (area under the curves) arise from wave vectors within the interval $k/k_0 < \sqrt{\epsilon_3}$. Note that, for a given film thickness, the values of the transmissivity spectrum are higher than those of the reflectivity one, and hence the transmissivity is expected to be higher than the reflectivity ($T_R > R_R$). This is confirmed by Fig. 7, not only for the Air/BaF₂ dielectric interface but also for the Air/Al₂O₃ one. For both interfaces, the radiation reflectivity (transmissivity) increases (decreases) as the film thickness increases, which is opposite to the behavior exhibited by the SPP counterpart shown in Fig. 4. This is reasonable given that

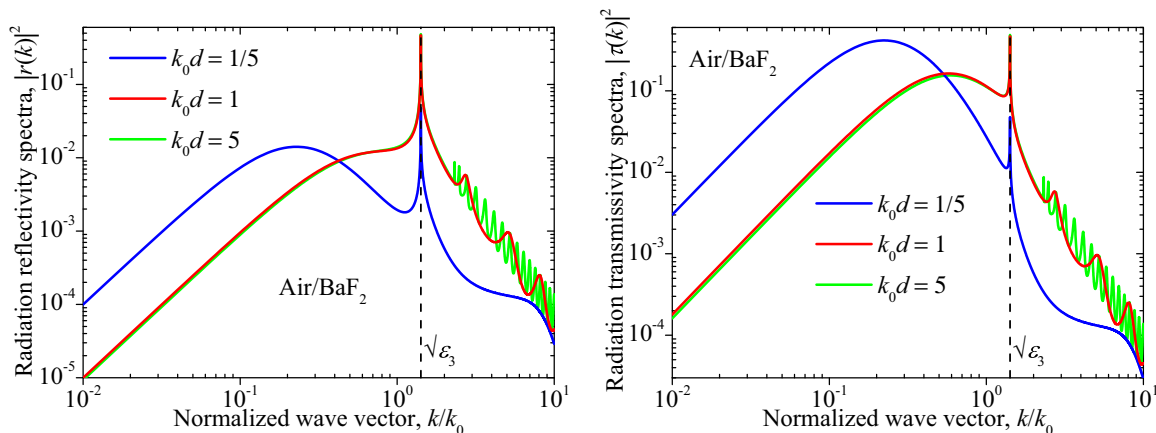


FIG. 6. (Color online) Spectra of the (a) radiation reflectivity and (b) radiation transmissivity as a function of the normalized radiation wave vector. Calculations were performed for three thicknesses of a film of SiO₂ and a dielectric interface of Air/BaF₂.

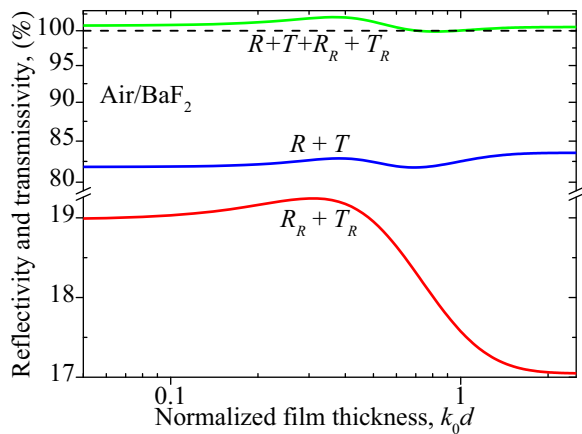


FIG. 8. (Color online) Reflectivity and transmissivity of the SPP and radiation fields, as a function of the normalized film thickness. Calculations were performed with the results shown in Figs. 4 and 7.

the energy of the incident SPP must be conserved. Both R_R and T_R increase as the permittivity mismatch of the dielectric interface increases from $\varepsilon_3 - \varepsilon_2 = 1/2$, (for Air/ Al_2O_3) to $\varepsilon_3 - \varepsilon_2 = 1$ (for Air/ BaF_2), as expected. For this change of the dielectric interface ($\Delta\varepsilon_3 = 0.5$) and $k_0d = 0.1$ ($d = 143$ nm), the variation of the reflectivity is $\Delta R_R = 0.5\%$, which rises to $\Delta T_R = 12.2\%$ for the transmissivity. These changes are smaller than the corresponding ones of the SPP reflectivity and SPP transmissivity shown in Fig. 4. Furthermore, the comparison of Figs. 4 and 6, for a particular thickness and dielectric interface, shows that $R > R_R$ and $T > T_R$, which indicates that reflected and transmitted SPP fields carry more energy than their radiation equivalents.

Figure 8 shows the film-thickness dependence of the reflected and transmitted power fractions involved in the SPP ($R + T$) and radiation ($R_R + T_R$) fields, as well as their overall sum, for the Air/ BaF_2 dielectric interface. The fact that $R + T \gg R_R + T_R$ means that the major part of energy of the incident SPP is distributed between the reflected and transmitted SPPs, while less than 20% of its energy goes to the radiation fields. Note that $R + T + R_R + T_R \approx 1$, which satisfies quite well the principle of conservation of energy, with a deviation of less than 2% that occurs at $k_0d = 0.36$ ($d = 514$ nm). This deviation reduces to less than 0.5% for the dielectric interface of Air/ Al_2O_3 , due to its smaller permittivity mismatch than the one of the Air/ BaF_2 interface. It is therefore clear that, when the permittivities of the dielectric media are of the same order of magnitude, the proposed formalism is able to analytically describe with good accuracy the reflection and transmission of both the SPP and radiation fields generated at a dielectric interface. Given that Eqs. (15) and (20) have been derived assuming that the permittivities of the dielectric media are not so dissimilar, in general, this simple approach is expected to yield deviations higher than 2%, from the conservation of energy, as the difference of permittivities of the dielectric media increases to values larger than the unity ($\varepsilon_3 - \varepsilon_2 > 1$). In these cases, Eqs. (15a)–(15d) are not longer suitable and the determination of the reflection and transmission coefficients is much more complicated due to the presence of the radiation modes, as established by Eqs. (12)

and (13), which still hold and can be conveniently solved by means of a numerical approach.

IV. CONCLUSIONS

The reflection and transmission of a surface phonon-polariton propagating along the surface of a thin film of SiO_2 and crossing the interface of two dielectric media has been analysed by means of an analytical approach based on the expansion of the electrical and magnetic fields in terms of normal modes. Fresnel-like formulas for the reflectivity and transmissivity of both the polariton and radiation fields generated at the dielectric interface have been explicitly determined. For the dielectric interfaces of air/ BaF_2 and air/ Al_2O_3 , it has been shown that: (i) The polariton reflectivity (transmissivity) decreases (increases) as the film thickness increases, while its radiation equivalent follows the opposite behavior. (ii) In the polariton and radiation fields, the transmissivity is significantly more sensitive than the reflectivity to the changes on the permittivity mismatch of the dielectric interface. (iii) The reflectivity and transmissivity of the radiation fields are smaller than their polariton counterparts, which together account for around 82% of the energy of the incident surface phonon-polariton. The proposed formalism accurately fulfills the principle of conservation of energy and could be used for quantifying the polariton energy and radiation losses at a dielectric interface.

APPENDIX A: ORTHOGONALITY OF MODES

Let us consider that (e_n, h_n) and (e_m, h_m) are two different modes propagating along the system shown in Fig. 1 with $\varepsilon_3 = \varepsilon_2$, they then satisfy Eqs. (1a) and (1c)

$$\frac{\partial^2 h_n}{\partial x^2} - p_n^2 h_n = 0, \quad (\text{A1a})$$

$$\frac{\partial^2 h_m}{\partial x^2} - p_m^2 h_m = 0. \quad (\text{A1b})$$

We can see that Eqs. (A1a) and (A1b) define a classical Sturm-Liouville problem, and hence the orthogonality of the n th and m th modes can be easily proved multiplying Eq. (A1a) and the complex conjugate of Eq. (A1b) by h_m^* and h_n , respectively. The subtraction of the resulting equations yields

$$(p_n^2 - (p_m^2)^*) h_n h_m^* = \frac{\partial}{\partial x} \left(h_m^* \frac{\partial h_n}{\partial x} - h_n \frac{\partial h_m^*}{\partial x} \right). \quad (\text{A2})$$

By using Eqs. (1a) [$e = (\beta/\omega\varepsilon)h$] and (1b) [$e_z = (1/i\omega\varepsilon)\partial h/\partial x$] for each mode and integrating both sides of Eq. (A2), we obtain the following

$$\frac{p_n^2 - (p_m^2)^*}{i\beta_n} \int_{-d}^{\infty} e_n h_m^* dx = \left[e_{zn} h_m^* + \frac{\varepsilon^*}{\varepsilon} e_{zm}^* h_n \right]_{-d}^{\infty}. \quad (\text{A3})$$

The right-hand side of Eq. (A3) can be evaluated and simplified by splitting it for positions inside the thin film ($-d < x < 0$) and the dielectric medium ($x > 0$), applying the corresponding boundary conditions at $x = -d$ and $x = 0$, and taking into account the disappearance of the fields at $x = \infty$. The final

result is

$$\frac{p_n^2 - (p_m^2)^*}{i\beta_n} \int_{-d}^{\infty} e_n h_m^* dx = \left(\frac{\varepsilon_1^*}{\varepsilon_1} - \frac{\varepsilon_2^*}{\varepsilon_2} \right) e_{zm}^{(1)*} h_n^{(1)} \Big|_{x=-d}, \quad (\text{A4})$$

Equation (A4) thus indicates that when the permittivities of the thin film and the dielectric medium are real, the integral in its left-hand side vanishes

$$\int_{-d}^{\infty} e_n h_m^* dx = 0 \quad (\text{A5})$$

for any $n \neq m$. This orthogonality relation holds for any combination of SPP modes as well as for an inner product between SPP and radiation modes. Taking into account the definition of the Poynting vector in Eq. (21), Eq. (A5) establishes that the power cannot be transferred among different modes in lossless media. Even though real materials always exhibit losses, these become negligible at certain excitation frequencies, as is the case of SiO₂ and SiC [11,33]. This is the reason why in this work, we are considering lossless media, for which Eq. (A5) is valid. On the other hand, the normalization conditions of the SPP [Eq. (6a)] and radiation [Eq. (8a)] modes are straightforward to determine by direct integration of the modes in Eqs. (5) and (7), respectively.

APPENDIX B: SOLUTION OF THE SPP DISPERSION RELATION

By writing the in-plane wave vector as $\beta = \sqrt{\varepsilon}k_0$, the transverse wave vectors $p_n = \sqrt{\varepsilon - \varepsilon_n}k_0$ and the SPP dispersion

relation in Eq. (4) reads

$$\frac{\sqrt{\varepsilon - \varepsilon_2}}{\varepsilon_2} + \frac{\sqrt{\varepsilon - \varepsilon_1}}{\varepsilon_1} \tanh(\sqrt{\varepsilon - \varepsilon_1}\lambda) = 0, \quad (\text{B1})$$

where $\lambda = k_0d$ is the normalized film thickness. Considering that $\lambda < 1$, which is the case of interest to enhance the SPP energy transport [11], Eq. (B1) can be solved through perturbation theory. For an approximation up to λ^4 , Eq. (B1) takes the form

$$\frac{\sqrt{\varepsilon - \varepsilon_2}}{\varepsilon_2} + \frac{\varepsilon - \varepsilon_1}{\varepsilon_1} \lambda \left(1 - \frac{\varepsilon - \varepsilon_1}{3} \lambda^2 \right) = 0, \quad (\text{B2})$$

which indicates that the effective permittivity ε of the system has the following expansion

$$\varepsilon = \varepsilon_2 + \varepsilon^{(2)}\lambda^2 + \varepsilon^{(4)}\lambda^4. \quad (\text{B3})$$

The combination of Eqs. (B2) and (B3) yields the following values for the parameters $\varepsilon^{(2)}$ and $\varepsilon^{(4)}$

$$\varepsilon^{(2)} = \varepsilon_2^2 \left(1 - \frac{\varepsilon_2}{\varepsilon_1} \right)^2, \quad (\text{B4a})$$

$$\varepsilon^{(4)} = 2\varepsilon_1 \left(1 - \frac{\varepsilon_2}{\varepsilon_1} \right) \left[\frac{1}{3} - \left(\frac{\varepsilon_2}{\varepsilon_1} \right)^2 \right] \varepsilon^{(2)}. \quad (\text{B4b})$$

Equations (B4a) and (B4b) are valid for any complex permittivity ε_1 of the film. For a lossless film (ε_1 is a real number), however, these equations hold for $\varepsilon_1 < 0$ only. This is the condition of existence and propagation of SPPs along very thin films ($\lambda \ll 1$), which differs from the well known constraint $\varepsilon_1 < -\varepsilon_2$, valid for thick films ($\lambda \gg 1$).

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